



Docket No.: 4590-242

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of :  
Inventor(s): Pascal GABET et al. : Confirmation No. 5672  
U.S. Patent Application No. 10/722,593 : Group Art Unit: 2817  
Filed: November 28, 2003 : Examiner: n/a  
For: DEVICE AND METHOD FOR FREQUENCY SYNTHESIS WITH HIGH SPECTRAL  
PURITY

**SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56, 1.97 and 1.98, the attention of the Patent and Trademark Office is hereby directed to the documents listed on the attached form PTO-1449. It is respectfully requested that the documents be expressly considered during the prosecution of this application, and that the documents be made of record therein and appear among the "References Cited" on any patent to issue therefrom.

This Information Disclosure Statement is being filed within three months of the U.S. filing date OR before the mailing date of a first Office Action on the merits. No certification or fee is required.

Respectfully submitted,

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**Date: May 4, 2004**

INFORMATION DISCLOSURE  
CITATION IN AN  
APPLICATION

(PTO-1449)

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4590-242U.S. PATENT  
APPLICATION NO.  
10/722,593APPLICANT  
Pascal GABET et al.FILING DATE  
November 28, 2003GROUP  
2817

## U.S. PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE
	6,239,660	May 29, 2001	Dekker			

## FOREIGN PATENT DOCUMENTS

EXAMINER'S INITIALS	PATENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
						Yes	No

## OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)

EXAMINER	DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to Applicant.